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Form PTC	D-1449	P. L. L.	Attorney Docket No. 062020-1550		Serial No. 10/686,697				
INFORMATION DISCLOSURE CITATION APPLICATION Ko									
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			U.S. PA	TENT DOCUMEN	TS				_
Examiner Initials	Item	Document Number	Date	Name		Class	Subclass	Filing Date If Appropriate	
44	Α	2004/0,076,910	04/22/04	Rutter, Jr. et al.		430	311	04/05/03	
U	В	2004/0,126,694	07/01/04	Devoe et al.		430	270.1	06/15/00	
	С	2004/0,137,728	07/15/04	Gallagher et al.		438	689	09/13/03	
yes	D	6,121,340	09/19/00	Shick et al.		522	31	11/04/96	
			FOREIGN	PATENT DOCUM	ENTS				
		Document Number	Date	Country		Class	Subclass	Translation	
								Yes	No
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yet	E	WU, X. et al.: Lithographic Characteristics and Thermal Processing of Photosensitive Sacrifical Materials; Journal of the Electrochemical Society, 149, 10, G555-G561 (2002)							
gar	F	WU, et al.: Photoinitiation systems and thermal decomposition of photodefinable sacrificial materials; Journal of Applied Polymer Science, Volume 88, Issue 5, 2 May 2003, Pages 1186-1195.							

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